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| INFORMATION DISCLOSURE STATEMENT BY APPLICANT <i>(Multiple sheets used when necessary)</i> | Application No. | 10/576,405 |
| | Filing Date | April 30, 2007 |
| | First Named Inventor | Hada et al. |
| | Art Unit | 1795 |
| SHEET 1 OF 2 | | Examiner Anca Eoff |
| | | Attorney Docket No. SHIGA7.048APC |

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| *Examiner: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant. | | | |

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